



PATENT

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## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:  Rosato et al.  Application No.: 09/408,279  Filed: September 29, 1999  For: PROCESS AND SYSTEM FOR RINSING OF SEMICONDUCTOR SUBSTRATES	Group No.: -1746  Examiner: Kornakov  APPLICANT'S INTERVIEW SUMMARY
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**CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service as First Class Mail in an envelope, addressed to: Commissioner for Patents, Washington, DC 20231 on 12/10/01  
Dated: 12/10/01 By: [Signature]  
Name Janet Chan  
STALLMAN & POLLOCK LLP

Commissioner for Patents  
Washington, DC 20231

Sir:

Applicant's Interview Summary is being filed in response to the Examiner's Interview Summary (Paper No. 8), which was received by the undersigned on 21 November 2001.

The telephone interview took place on 3 October 2001 between Examiner Michael Kornakov and attorney Kathleen Frost. The outstanding Election/Restriction Requirement was discussed. Kathleen Frost requested clarification as to the Examiner's expectations in a response and Mr. Kornakov elaborated on his expectations. No specific election was made during the phone conference.

Respectfully submitted,

STALLMAN & POLLOCK LLP

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